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(71) Applicant (for all designated States except US): **PREMIER REFRACTORIES (BELGIUM) S.A.** [BE/BE];
Rue de la Rivière, 100, B-7330 Saint-Ghislain (BE).

(72) Inventors; and

(75) Inventors/Applicants (for US only): **SABRE, Serge** [FR/FR]; Place Ambroise Croizat 25, F-62640 Montigny-en-Gohelle (FR). **JONAS, Christophe** [BE/BE]; Rue des Aubépines 5, B-7380 Quiévrain (BE).

(74) Agent: **DEBLED, Thierry**; Vesuvius Group S.A., Intellectual Property Dept., Rue de Douvrain, 17, B-7011 Ghlin (BE).

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(54) Title: REFRACTORY COMPOSITION AND PROCESS FOR THE REPAIR OF A HOT REFRACTORY WALL

(57) Abstract: The present invention relates to refractory composition consisting essentially of 40-90 dry weight % of amorphous silica aggregates, up to 40 dry weight % of alumina based compounds 10-15 dry weight % of clay, 0.2-2.0 dry weight % of a chemical binder and further containing 2 to 8% of water. These compositions are particularly useful for the repair of coke oven damaged wall in a gunning process.



WO 2004/085341 A1